L Number	Hits	Search Text	DB	Time stamp
1	1388	phase adj shift adj mask	USPAT; US-PGPUB	2003/04/03 13:14
2	1113	(phase adj shift adj mask) and (etch or etching or etched)	USPAT; US-PGPUB	2003/04/03 13:15
3	1066	((phase adj shift adj mask) and (etch or etching or etched)) and (light or optics or optical or reflected or scatter or scattering or scatterometry or scattered)	USPAT; US-PGPUB	2003/04/03 14:36
4	203	((phase adj shift adj mask) and (etch or etching or etched)) and (scatter or scattering or scatterometry or scattered)	USPAT; US-PGPUB	2003/04/03 13:48
5	0	((phase adj shift adj mask) and (etch or etching or etched)) and apparatus.clm	USPAT; US-PGPUB	2003/04/03 13 48
6	162	((phase adj shift adj mask) and (etch or etching or etched)) and apparatus.clm.	USPAT; US-PGPUB	2003/04/03 14 35
7	378	156/345.24,345.25,345.3,345.5.ccls.	USPAT, US-PGPUB	2003/04/03 14 36
8	158	156/345.24,345.25,345.3,345.5.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered)	USPAT. US-PGPUB	2003/04/03 15 13
9	76	(156/345.24,345 25,345.3,345.5.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) and mask	USPAT. US-PGPUB	2003/04/03 14 53
10	82	(156/345.24,345 25,345.3,345.5.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) not ((156/345.24,345.25,345.3,345.5.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) and mask)	USPAT, US-PGPUB	2003/04/03 15 07
11	220	156/345.24,345.25,345.3,345.5.ccls. not (156/345.24,345 25,345.3,345.5.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered))	USPAT; US-PGPUB	2003/04/03 15 13
12	839	118/712.ccls.	USPAT; US-PGPUB	2003/04/03 15:13
13	226	118/712.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered)	USPAT. US-PGPUB	2003/04/03 15:21
14	12441	438//$.ccls. or 216/$.ccls.	USPAT. US-PGPUB	2003/04/03 15:21
15	226	(118/712.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) and (reflected or reflecting or scatter or scattering or scatterometry or scattered)	USPAT. US-PGPUB	2003/04/03 15:21
16	134	((118/712.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) and apparatus.clm.	USPAT, US-PGPUB	2003/04/03 15:22
17	1885	(438//$.ccls. or 216/$.ccls.) and (reflected or reflecting or scatter or scattering or scatterometry or scattered)	USPAT. US-PGPUB	2003/04/03 15:35
18	348	((438//$.ccls. or 216/$.ccls.) and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) and apparatus.clm.	USPAT; US-PGPUB	2003/04/03 15:22
19	287	(((438//$.ccls. or 216/$.ccls.) and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) and apparatus.clm.) not (((118/712.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) or (118/712.ccls. and (reflected or reflecting or scatter or scattering or scatterometry or scattered)) or 156/345.24,345.25,345.3,345.5.ccls. or (((phase adj shift adj mask) and (etch or etching or etched)) and (scatter or scattering or scatterometry or scattered)))	USPAT; US-PGPUB	2003/04/03 15:27
20	657	((c or cyrus) near2 tabery).in. or ((k or khoi) near2 phan).in. or ((b or bharath) near rangarajan).in. or ((b or bhanwar) near singh).in. or ((r or ramkumar) near subramanian).in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/04/03 15:35
21	70	(((c or cyrus) near2 tabery).in. or ((k or khoi) near2 phan).in. or ((b or bharath) near rangarajan).in. or ((b or bhanwar) near singh).in. or ((r or ramkumar) near subramanian).in.) and (reflected or reflecting or scatter or scattering or scatterometry or scattered)	USPAT; US-PGPUB	2003/04/03 15:35